

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants:	Heng Liu		
Assignee:	BridgeLux, Inc.		
Title:	Chemical Vapor Deposition Reactor		
Application No.:	10/727,746	Filing Date:	December 3, 2003
Examiner:	Ram N. Kackar	Group Art Unit:	1792
Docket No.:	M-15626-1D US	Confirmation No.:	8880

Irvine, California
February 6, 2009

Via EFS Web Transmission

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE TO OFFICE ACTION

Dear Sir:

This communication is in response to the non-final Office Action dated October 6, 2008.

Claims begin on page 2.

Remarks begin on page 11.